

# ZnO/Au Hybrid Layered Structure on Silk Textile Prepared by Supercritical CO<sub>2</sub> Promoted Electrodeposition for Applications in Flexible Multifunction Electronic Devices

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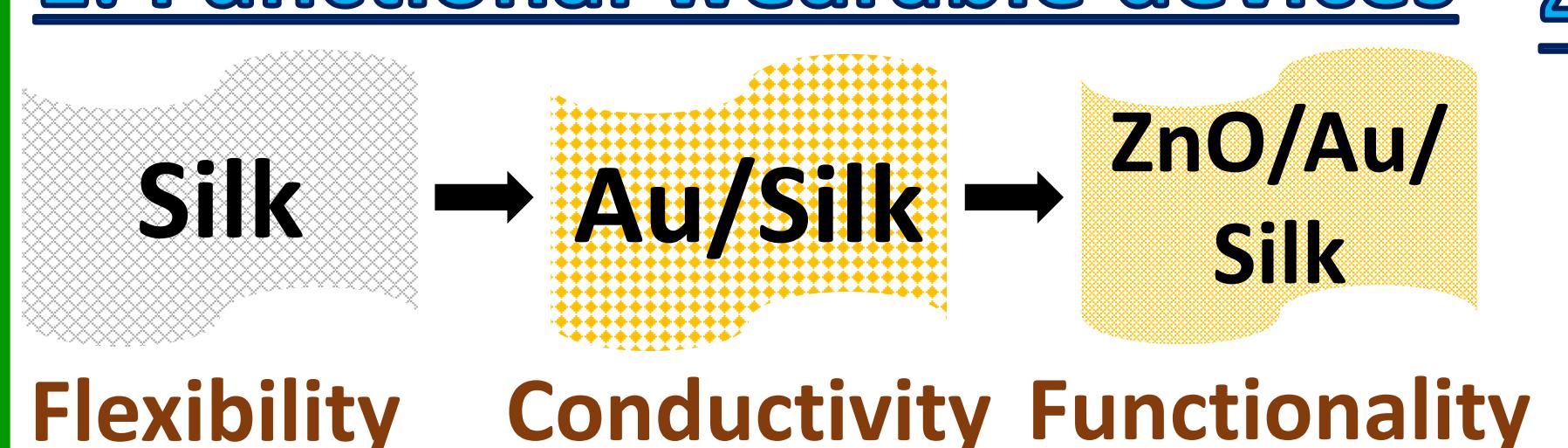
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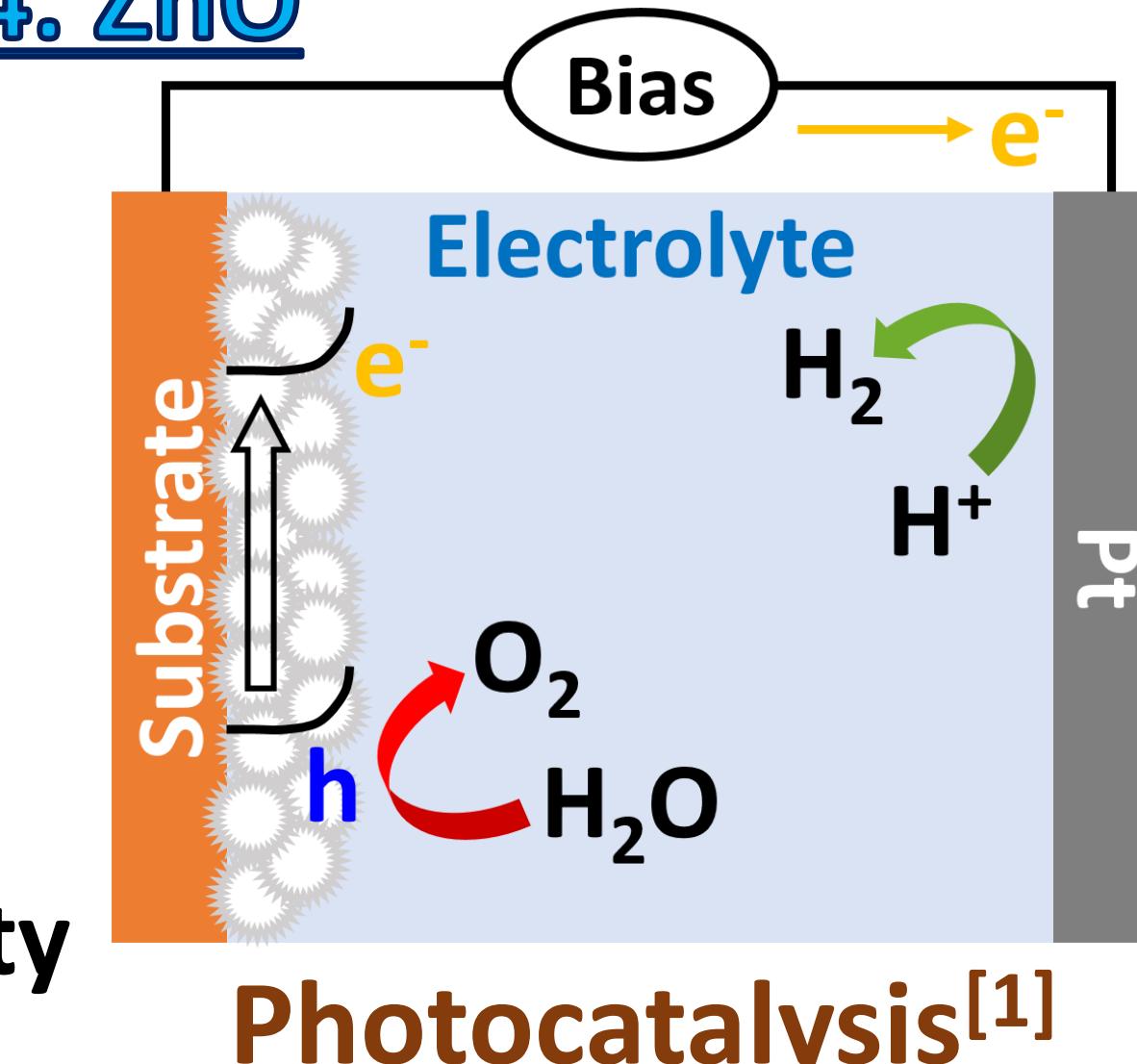
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## • Motivation & Introduction •

### 1. Functional wearable devices



### 4. ZnO



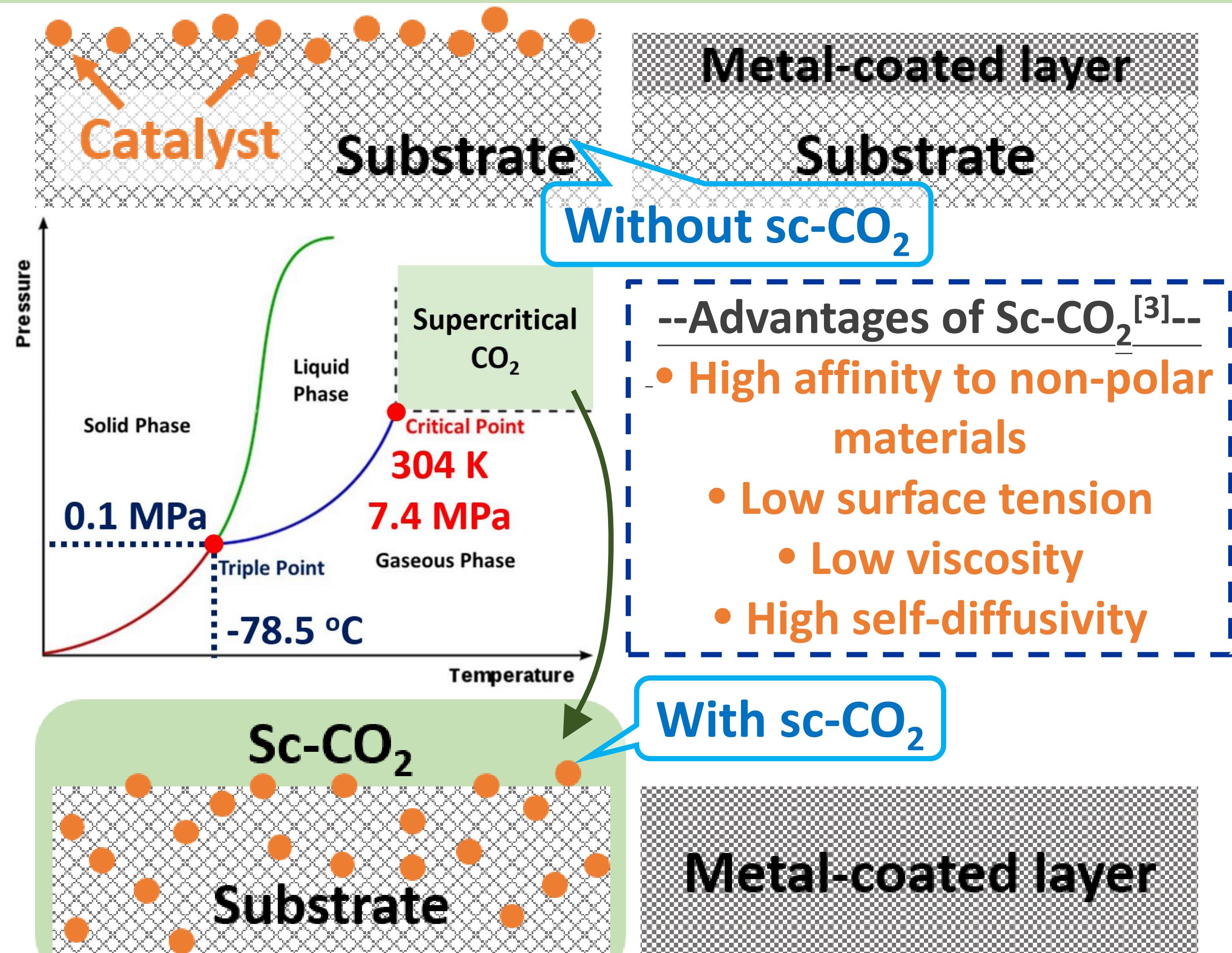
### 2. Merits of Au [2]

- Biocompatibility
  - Ductility
  - Corrosion

### 3. Silk

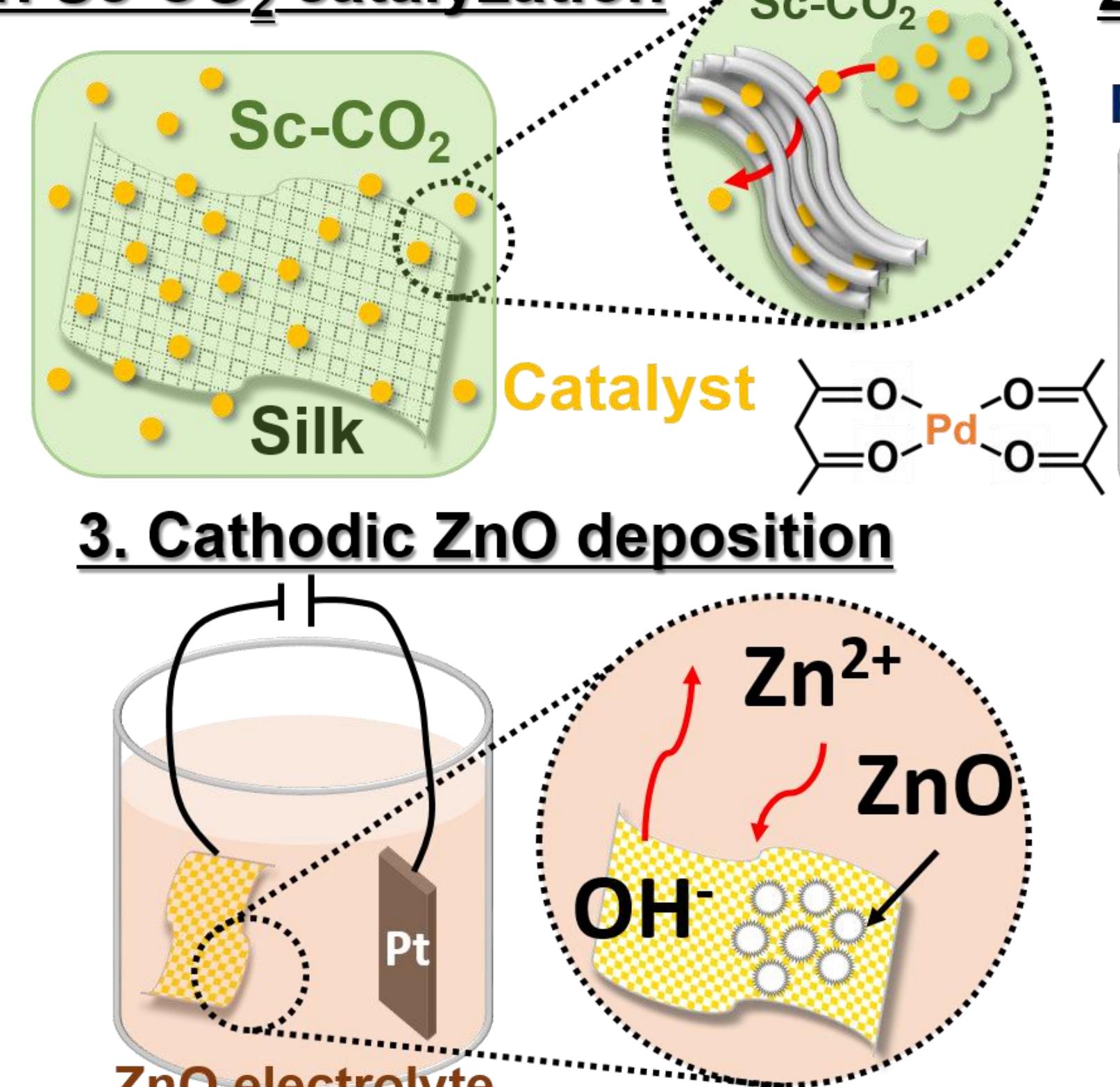
- Stretchability
- Biocompatibility

## • Supercritical CO<sub>2</sub> (Sc-CO<sub>2</sub>) assisted step •

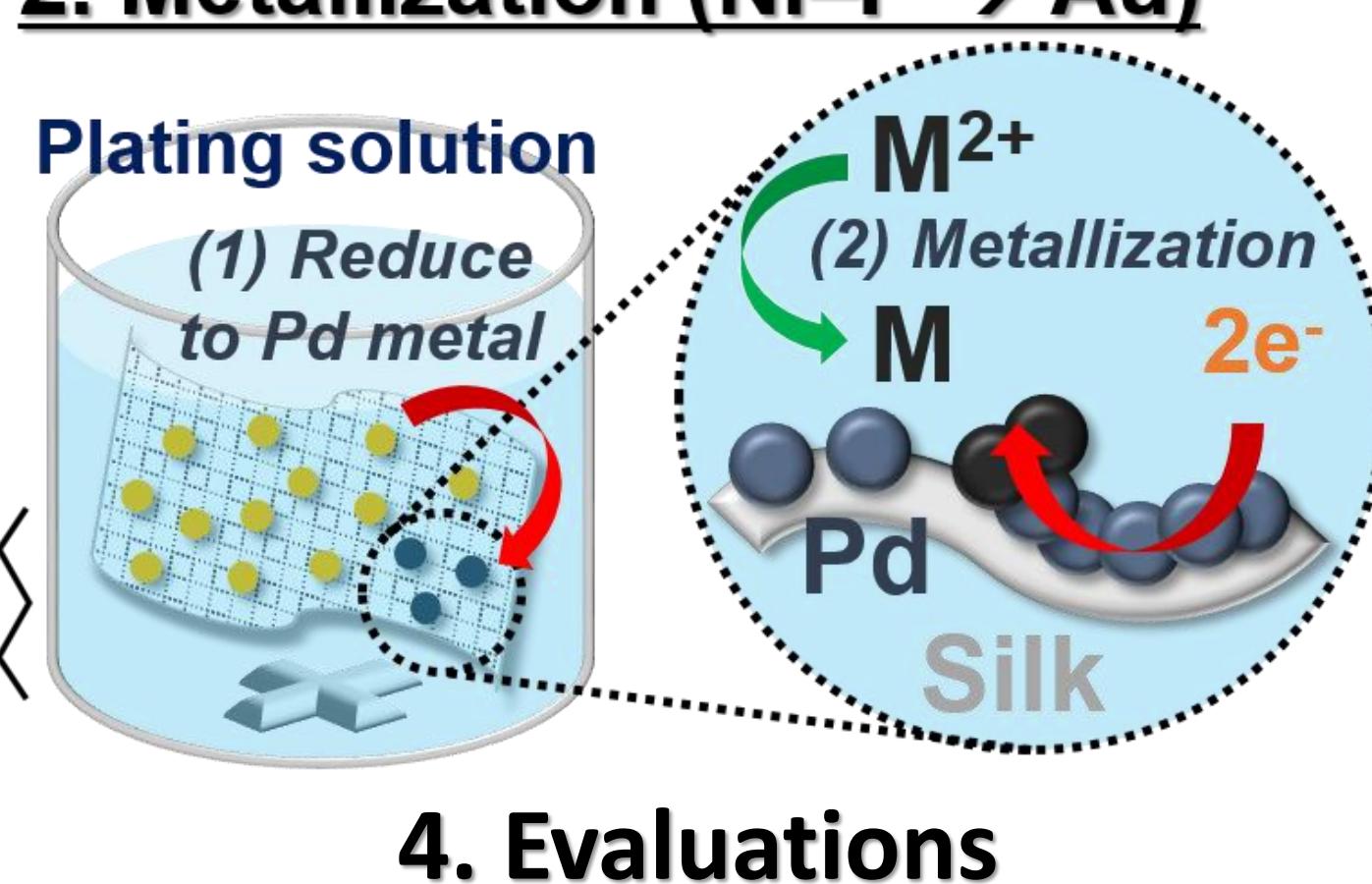


## • Experimental procedures •

### 1. Sc-CO<sub>2</sub> catalyzation



### 2. Metallization (Ni-P → Au)



### 3. Cathodic ZnO deposition

- Surface morphology
- Crystal structure
- Electrical conductivity
- Adhesive firmness
- Photocatalytic activity

### 4. Evaluations

- Surface morphology
- Crystal structure
- Electrical conductivity
- Adhesive firmness
- Photocatalytic activity

## • Results and Discussion I – Metallization •

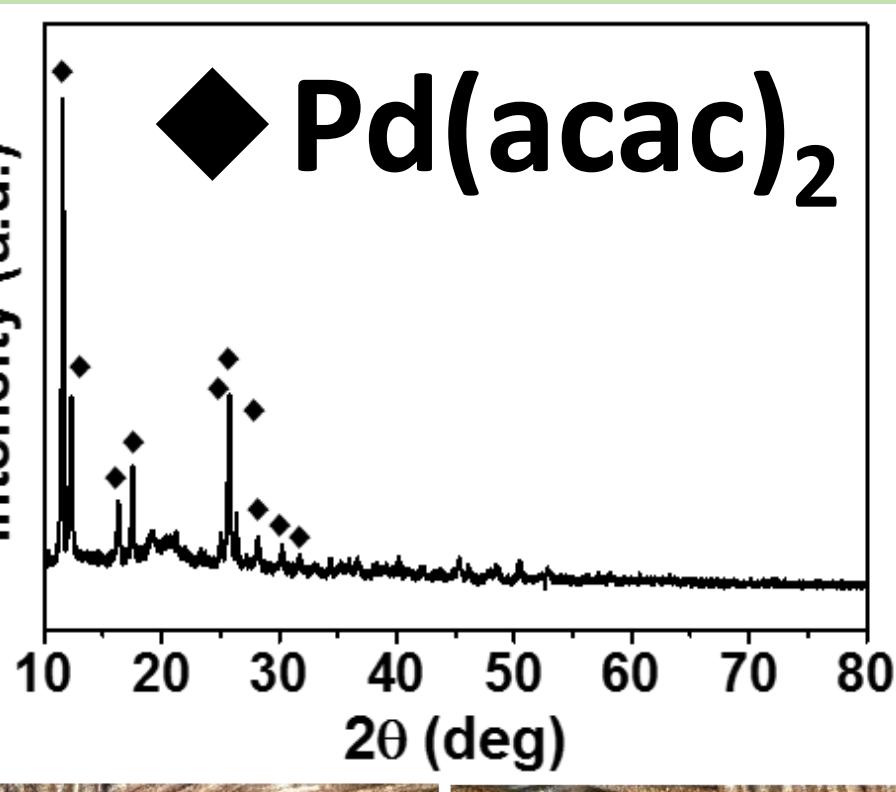
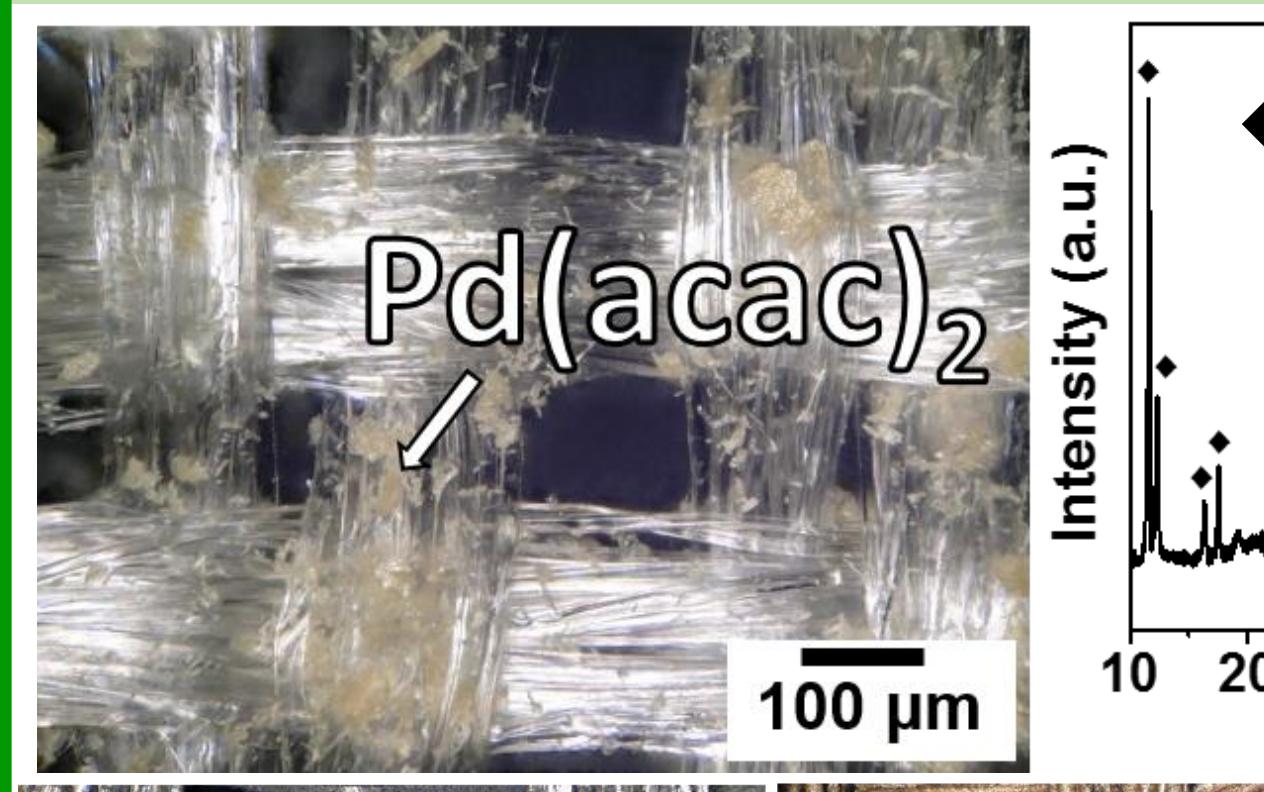


Fig. 1 (a) OM image and (b) XRD pattern of silk textile after sc-CO<sub>2</sub> catalyzation.

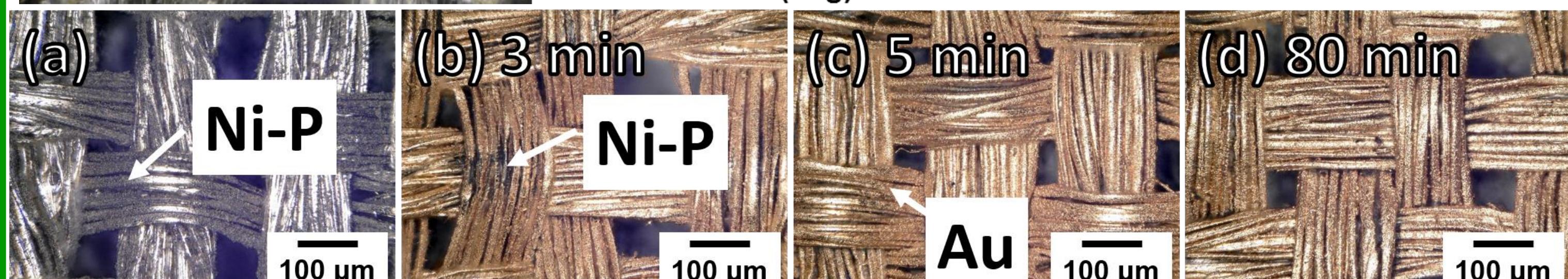


Fig. 2 Au metallization at (a) 0, (b) 3, (c) 5, and (d) 80 min.

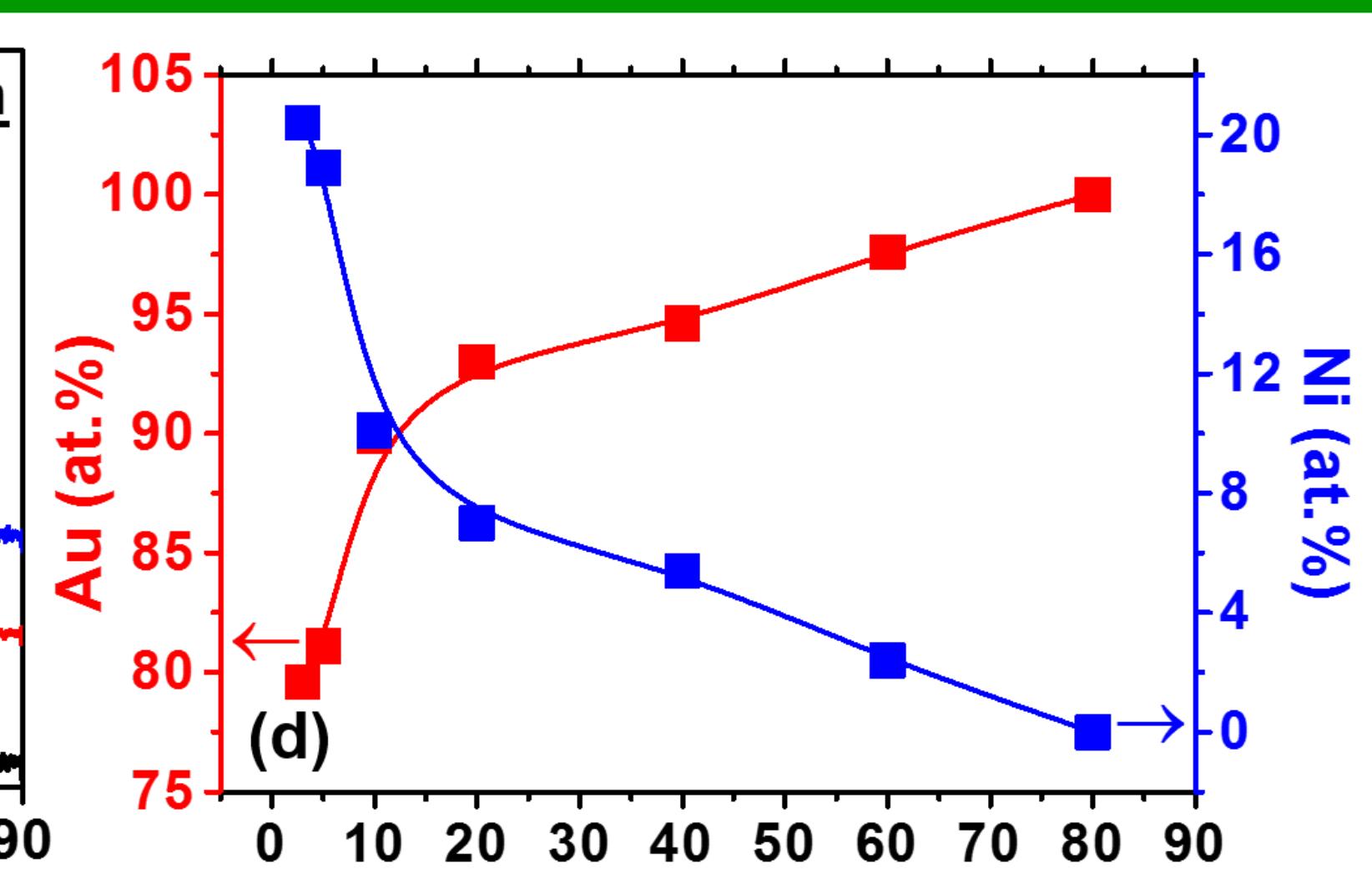
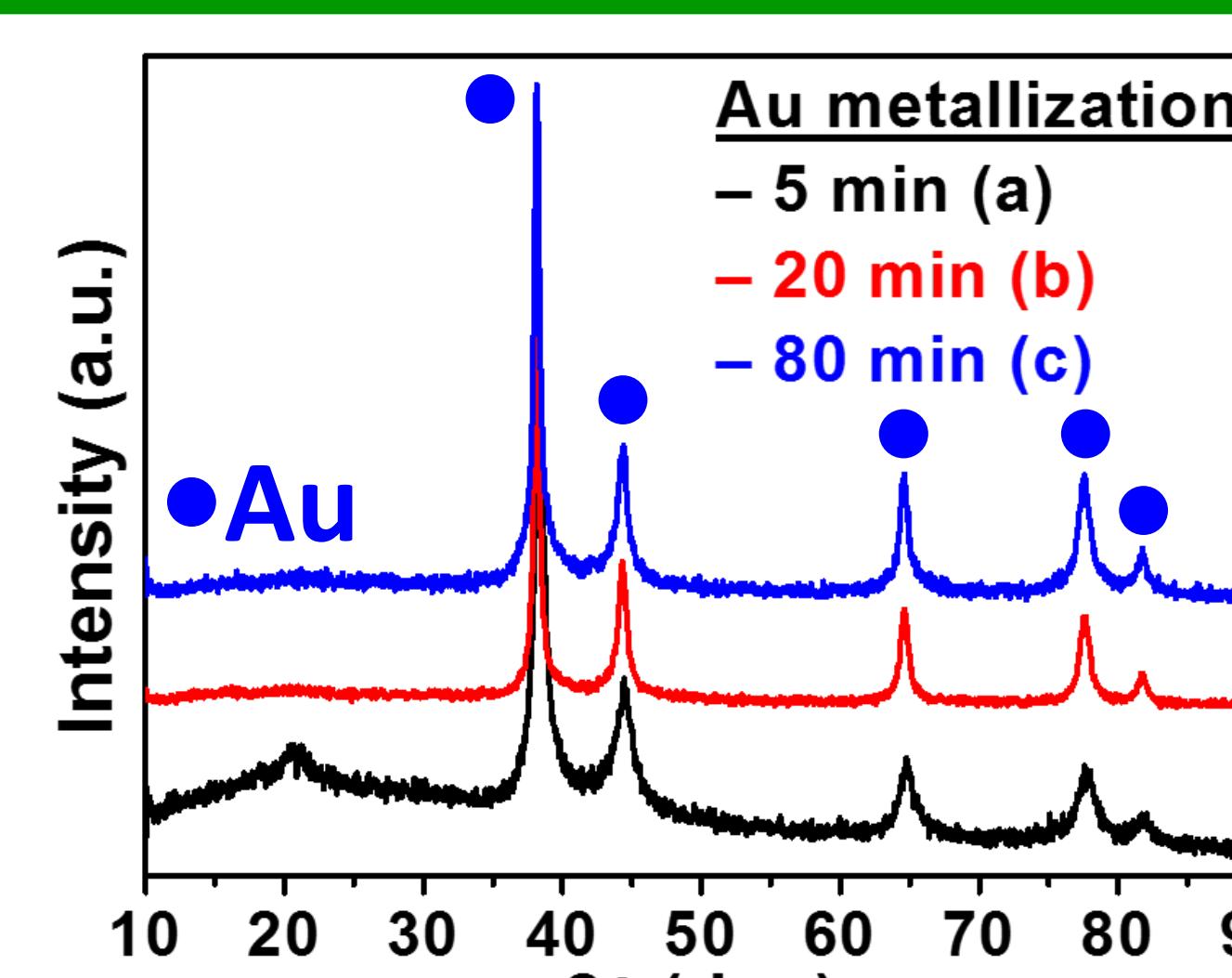


Fig. 3 XRD patterns of Au/silk at the metallization time of (a) 5, (b) 20, and (c) 80 min and (d) composition of Au/silk composite.

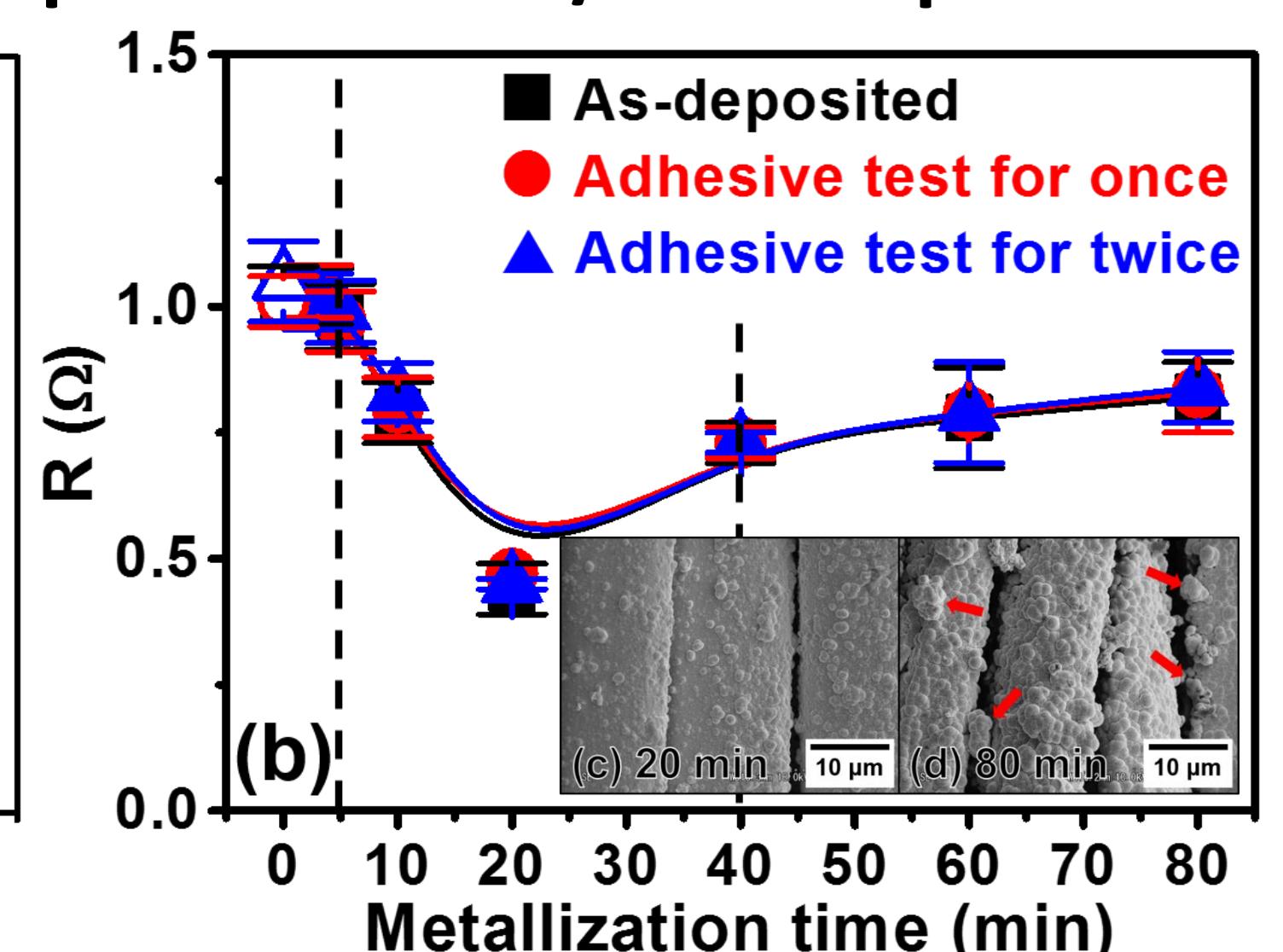
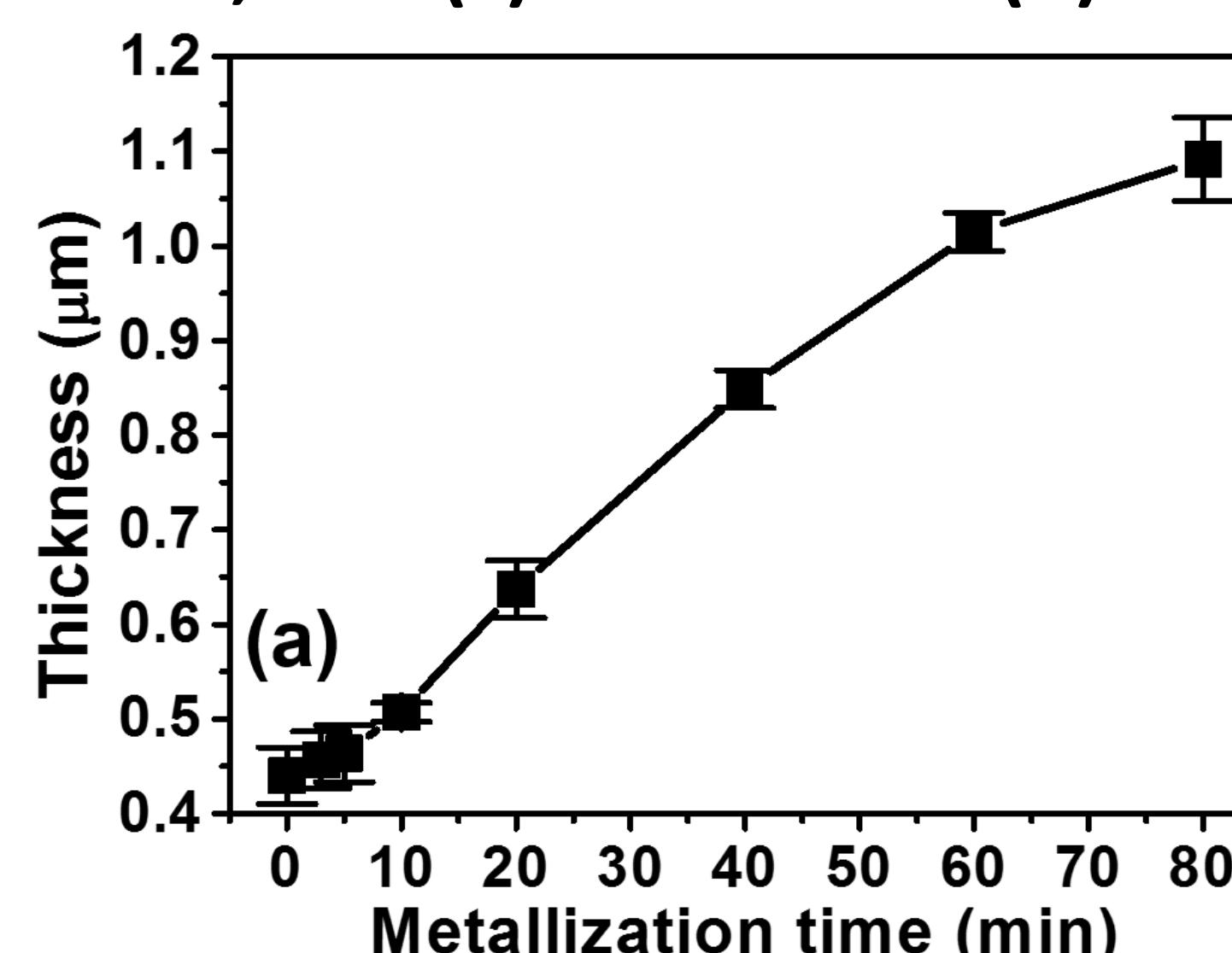


Fig. 4 (a) Au thickness – metallization time, (b) electrical resistance of Au/silk, and SEM images at metallization of (c) 20 and (d) 80 min.

## • Results and Discussion II – ZnO deposition •

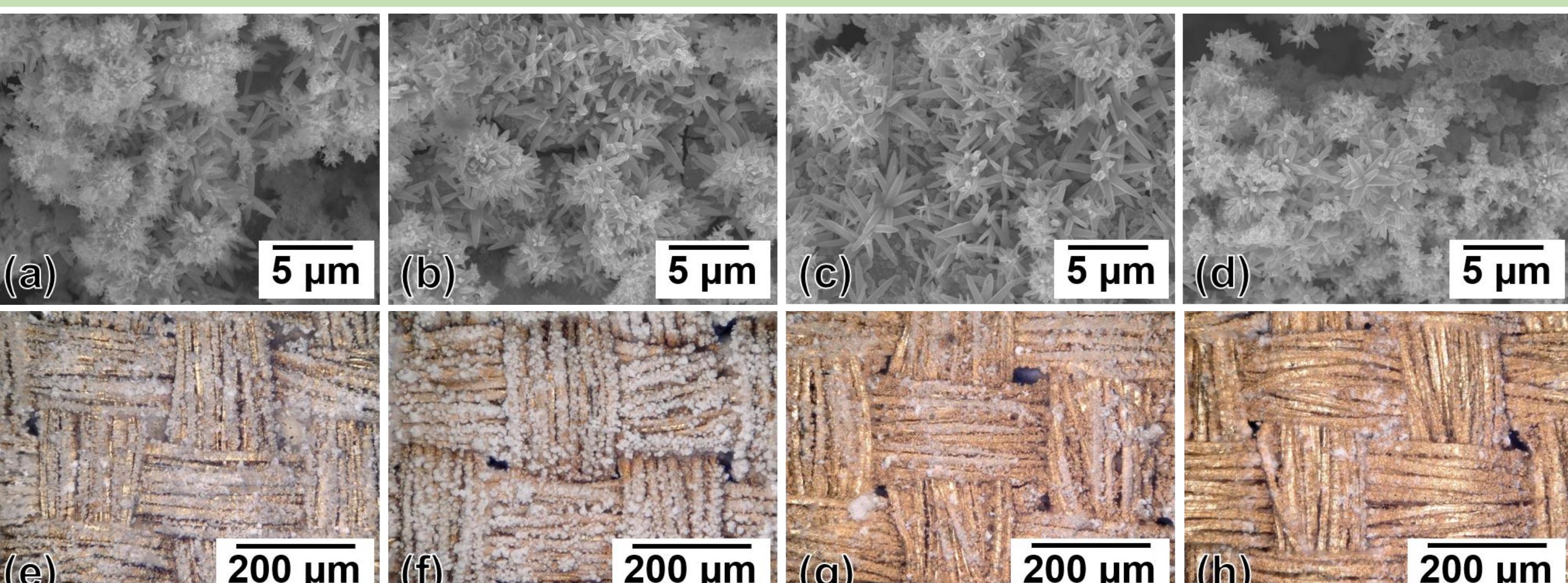


Fig. 5 ZnO deposited SEM images on Au/silk with (a) 0 wt.%, (b) 0.1 wt.%, (c) 0.2 wt.%, and (d) 0.3 wt.% and OM images on Au/silk with (a) 0 wt.%, (b) 0.1 wt.%, (c) 0.2 wt.%, and (d) 0.3 wt.% [H<sub>2</sub>O<sub>2</sub>].

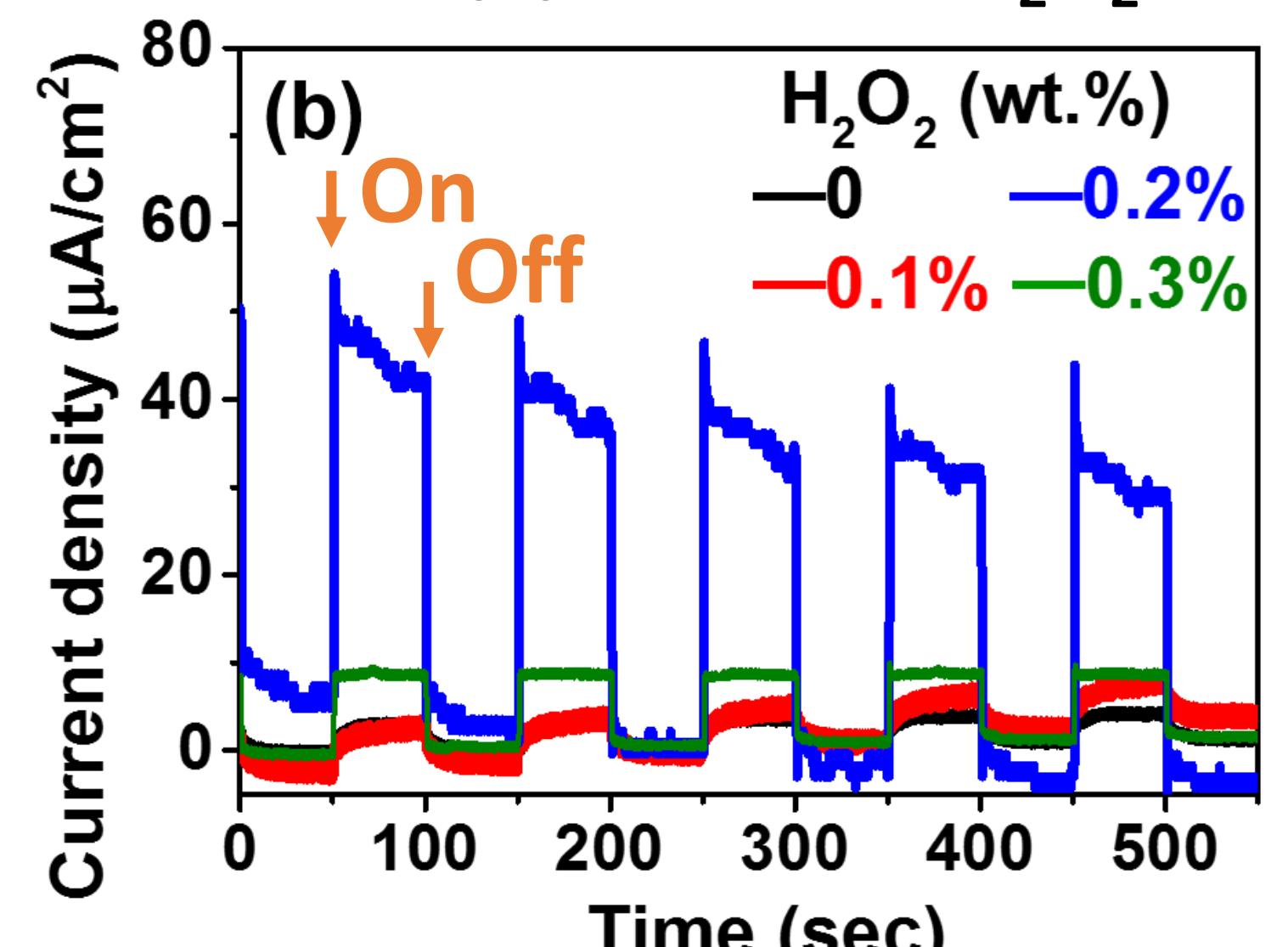
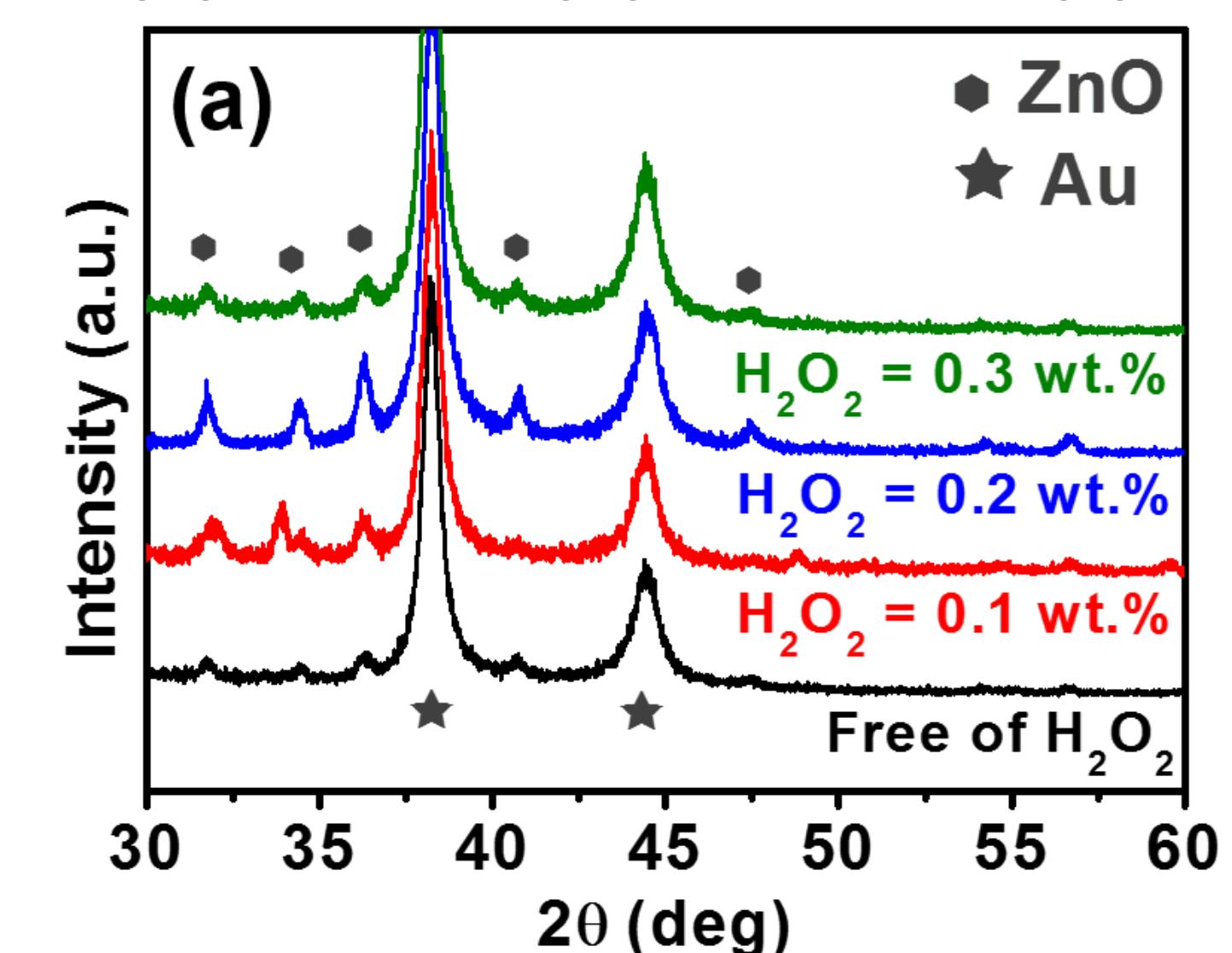


Fig. 6 (a) XRD patterns and (b) photocurrent density of the ZnO/Au/silk hybrid materials in 0.5 M Na<sub>2</sub>SO<sub>4</sub> with various [H<sub>2</sub>O<sub>2</sub>].

## • Conclusions •

### Silk/Au/ZnO



Fig. 7 Silk/Au/ZnO composite material

- Flexible, conductive, and photocatalytic composite Silk/Au/ZnO materials.
- Integration of ZnO (functional material) and silk textile (cloth material) together to make the materials close to daily life.
- Photocurrent density enhanced 11.5 times with the optimized deposition electrolyte by cathodic deposition.